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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Lee et al.

Serial No.: 09/358,940

Filed: July 22, 1999

For: HIGH SELECTIVITY BPSG TO
TEOS ETCHANT

Examiner: V. Perez-Ramos

Group Art Unit: 1765

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AMENDMENT ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION

Commissioner for Patents
Washington, D.C. 20231

Sir:

The following amendments and remarks are filed in response to the Examiner's remarks in the Final Office Action mailed September 8, 2000, the three-month shortened statutory period for response to which expires on December 8, 2000, and to the Advisory Action mailed on November 20, 2000 refusing entry of Applicants' Amendment under 37 C.F.R. § 1.116 as raising new issues requiring a further search. This response is submitted in conjunction with a Request for Continued Examination less than three months from the mailing date of the Final Office Action.

IN THE CLAIMS:

Please amend the claims as follows:

1. (Amended three times) An etchant solution which selectively etches borophosphosilicate glass over tetraethyl orthosilicate, said etchant solution comprising an organic acid and a fluoride-